IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the application of:

Boyd et al.

Boyd et al.

Croup Art Unit: 1746

Application No.: 10,606,022

Docket No.: LAM2P425

Filed: June 24, 2003

Date: April 28, 2006

For: SYSTEM AND METHOD FOR INTEGRATING IN-SITU METROLOGY
WITHIN A WAFER PROCESS

CERTIFICATE OF MAILING

I hereby certify that this correspondence is being deposited with the United States Postal Service as First Class Mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22213, 1450 on April 28, 2006.

Alexandria, VA 22313-1450 on April 28, 2006.

Justine Stamm

RESPONSE TO RESTRICTION REQUIREMENT

Mail Stop: Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313

Signed:

Dear Sir:

In response to the Restriction Requirement dated April 19, 2006, the Applicant(s) hereby elect, without traverse, group II, claims 11-20, to prosecute in the above-identified patent application. The Applicant(s) reserve the right to file a divisional application covering the subject matter of the non-elected claims.

Applicant(s) believe that no fees are required in the filing of this Response. However, if it is determined that any fees are required, the Commissioner is authorized to charge such fees to our Deposit Account No. 50-0805 (Order No. LAM2P425). Should the Examiner have any questions concerning this matter, the undersigned can be reached at the telephone number set out below.

Respectfully submitted,

MARTINE PENILLA & GENCARELLA, LLP

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Attorney Docket: LAM2P425